How to create your idHAL?

https://doc.archives-ouvertes.fr/compte-et-profil/

« I already have an account on HAL! Why do I need an IdHAL? » The HAL account is used to connect to the platform and to make submissions using a login and a password. The IdHAL is a unique author identifier, different from the login. It allows to link a production to a single author profile.

Log in to your HAL account on https://hal.archives-ouvertes.fr/ or apply for access on the login page.

In case of a first sign in, you will be asked to set your submission preferences. If you have already set up your account, go to step 3 : your idHAL creation.

1. Submission preferences

In My Space/My Profile tab, select submission preferences and make your choices.

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Profile information				
Submission preferences	—			
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	You can modify your submission preferences	here		
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	Affiliation(s)	Please enter the name or acronym of your laboratory and select it in the list.		selected
Choose IEMN affiliation	Find authors affiliations automatically	Institut d'Électronique, de Microélectronique et de Nanotechnologie (IEMN) - UMR 8520 EWN (2021)		~
(id: 1066983) and		Université de Lille - UPHE Université Polytechnique Hauts-de-France Ecole Centrale de Lille		
groupe (ex : CMNF-		- CNIS Centre National de la Recherche Scientifique - JUNIA JUNIA consult		
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		 EMN institut d'Electronique, de Microèlectronique et de Nanotachnologie (EMN) - UMN 8520 		
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		Centrale de Misro Nanio Fabrication - IEMN DMNE - IEMN (2021) (1697400) X Institut d'Electronique, de Microbi-Microlique et de Necolacheologie (IEMN) - UMR (525) (2001 (2021) (169646) X		
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Save your submission preferences.

2. Email alert preferences

Profile information	
Submission preferences	
E-mail alert preferences	In order to be automatically notified by email when a submission is put online, check the corresponding box(es)
	Receive your submission confirmation
Receive your submission confirmation Yes	Receive the notifications when you are
	Identified as a co-author

Check the box "receive notifications when you are identified as an author": you will be notified by emails allowing you to confirm that you are indeed a co-author of the work: the submission is then listed in your profile and you will be able to modify/complete it.

3. idHAL creation :

In the tab My profile/ profile information

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Choose the desired string of characters for your idHAL (HAL usually proposes 'first name-name'). You may want to indicate other possible author identifiers (arXiV, idRef,...). To connect your ORCID to your HAL profile. Be sure to have your orcid.org login information

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	Accueil Dépôt Consultation - Red Regroup author forms and create your IdHAL	cherche Documentation Mon espace -				
	Identifiers	Required fields				
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	Others researcher identifiers	Align your IdHAL with others researcher identifiers		arXiv• 🕂		arXiV,
	Social networks URLs	Add your links to social networks		arXiv VIAF		

Then, connect existing author forms to your idHAL. Indicate a first variant (ex: first name and name) in the search area:

Mes formes auteur

Mes forme	s auteur		
۲	Ghizlane Boussatour		Look for
0	Ghizlaine Boussatour	8	author forms. Click
Ajouter une forme :	Boussatour		to add.
	Ajouter une nouvelle forme		
	G. Boussatour		

Reproduce the operation with different forms, trying only last name to cast a wide net, or trying possible variants of your name (initial, initial + dot, compound names, marital name, possible misspellings used by the co-authors, etc.).

Click on « Show publications based on your author forms »

Sho eck the	w publications b e relevance o	ased on your author forms 3 f the associated docume	Q Search		
uter des	publications				
Liste des pr	ublications qui contienne sultats seront affichés.	nt les formes auteurs que vous avez choisies. Sél	ectionnez les publicatior	s à associer à votre idHAL pui	s les ajouter.
	(10.1109/DTIP54218.2	021.9568671). (hal-03541057)	Ohiologo December 2	Turnel Land Thermol	
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	Ghizlane Boussatour. fréquence. Micro et na (tel-03622465)	Caractérisation diélectrique et thermique de films l notechnologies/Microélectronique. Université de L	biopolymères pour l'élec ille, 2019. Français. (NM	tronique flexible haute IT : 2019LILUI015).	Ghizlane Bouss 🗸
	Ghizlane Boussatour, biosourced polylactic a <i>Microwave Workshop</i> Pavia, Italy. pp.1-3, (10	Pierre-Yves Cresson, Benoit Genestie, Nicolas Jo koid (PLA) substrate in a wide frequency range (0, Series on Advanced Materials and Processes for 0.1109/imws-amp.2017.8247428). (hal-03263973)	ly, T. Lasri. Characteriza 5-26 GHz). 2017 IEEE I RF and THz Application.	tion of biodegradable and <i>ITT-S International</i> s (<i>IMWS-AMP</i>), Sep 2017,	Ghizlane Bouss v
1	Ghizlane Boussatour, thermal conductivity of pp.503-510. (10.1016/	Pierre-Yves Cresson, Benoit Genestie, Nicolas Jo flexible biosourced polymers using the 3-omega i .polymertesting.2018.07.026). (hal-02625518)	ly, Jean-François Brun, nethod. <i>Polymer Testin</i> g	et al Measurement of the 7, Elsevier, 2018, 70,	Ghizlane Bouss ~
Unche	ck			2	
irreleva	ant				Fermer Ajoute
rererer	ices ,				

Add and save.

Save when you are sure you have scanned all author forms. Choose the default form to display.

Last confirmation : green publications are attached to profile and red ones are rejected

Confirmation MAJ des	publications rattachées à votre profil	
Publications ajoutées		
Publications retirées		
	substrate in a wide frequency range (0,5-26 GHz). 2017 IEEE MTT-S International Microwave Workshop Series on Advanced Materials and Processes for RF and THz Applications (IMWS-AMP), Sep 2017, Pavia, Italy. pp.1-3, (10.1109/imws-amp.2017.8247428). (hal-03263973)	,
Ghizlane Boussatour	Ghizlane Boussatour, Pierre-Yves Cresson, Benoit Genestie, Nicolas Joly, Jean-François Brun, et al. Measurement of the thermal conductivity of flexible biosourced polymers using the 3-omega method. <i>Polymer Testing</i> , Elsevier, 2018, 70, pp.503-510. (10.1016/j.polymertesting.2018.07.026). (hal-02625518)	
Ghizlane Boussatour	Yannick Dusch, Cécile Ghouila-Houri, Aurélien Mazzamurro, Ghizlane Boussatour, Hatem Dahmani, et al Mise en œuvre de capteurs RF-MEMS acoustiques pour l'industrie 4.0. 16emes journées pédagogiques du <i>CNFM, JPCNFM'2021</i> , CNFM, Dec 2021, Saint-Malo, France. 6 p., J3eA Hors-série 1 - Actes JPCNFM'2021, Volume 21 (2022), (10.1051/j3ea/20221019). (hal-03464507)	
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End of idHAL creation